RECEIPT

**PATENT** 

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of	)
Linda BRALY et al.	)
Application No. 10/002,676	)
Filed: October 31, 2001	)
For: METHOD FOR PLANARIZATION ETCH WITH IN-SITU MONITORI BY INTERFEROMETRY PRIOR T RECESS ETCH	ING )

Date: February 11, 2002

Docket No. LAM2P298

Examiner: Not Assigned

Group Art Unit: 1765

**CERTIFICATE OF MAILING** 

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope addressed to: Commissioner for Patents, Washington, DC 20231 on February 11, 2002.

Diane Schwanbeck

### REQUEST FOR CORRECTED FILING RECEIPT

Commissioner for Patents Office of Initial Patent Examination's **Customer Service Center** Washington, D.C. 20231

Sir:

Applicants respectfully request issuance of a new Filing Receipt for the aboveidentified patent application that correctly lists the title of the invention. A copy of the Filing Receipt with the requested change noted thereon is attached.

Applicants submit that no fee is due because the U.S. Patent and Trademark Office caused the error for which correction is requested. Nevertheless, in the event it is determined that any fees are due, such fees may be charged to Deposit Account 50-0805 (Order No. LAM2P298).

> Respectfully submitted, MARTINE & PENILLA, LLP

Edmund H. Mizumoto, Esq. Reg. No. 46,938

710 Lakeway Drive, Suite 170 Sunnyvale, CA 94085 Telephone (408) 749-6900 Customer No. 25920

Attorney Docket No. LAM2P298



## NIZED STATES PATENT AND TRADEMARK OFFICE

COMMISSIONER FOR PATENTS UNITED STATES PATENT AND TRADEMARK OFFICE

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GRP ART UNIT

FIL FEE REC'D

ATTY DOCKET NO

DRAWNGS

TOT CLAIMS IND CLAIMS

APPLICATION NUMBER 10/002,676

FILING DAME 7R40/01/2001

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**CONFIRMATION NO. 4626** 

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25920 MARTINE & PENILLA, LLP 710 LAKEWAY DRIVE SUITE 170

SUNNYVALE, CA 94085

FILING RECEIPT

\*OC000000007226551\*

Date Mailed: 12/21/2001

Receipt is acknowledged of this nonprovisional Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE. NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please write to the Office of Initial Patent Examination's Customer Service Center. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

#### Applicant(s)

Linda Braly, Albany, CA; Vahid Vahedi, Albany, CA; Erik Edelberg, San Francisco, CA; Alan Miller, Moraga, CA;

Domestic Priority data as claimed by applicant

Foreign Applications

If Required, Foreign Filing License Granted 12/21/2001

Projected Publication Date: Request for Non-Publication Acknowledged

Non-Publication Request: Yes

Early Publication Request: No

Title

Method-and planarization etch with in-situ monitoring by interferometry prior to recess etch

**Preliminary Class** 

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